



DISPOSABLE V-BANK ADSORBER

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Total detention modular bias-cut design				Low pressure drop and high efficiency			
the second se	nitial/retrofit applie ad & side-access ar		All and a second	ninates expe sting equipm		costs by using	
Optional imp media availa	regnated carbons ble	and othe		ntrol wide va e filter	riety of conto	aminants with	
Model	Face Size (in) No. of Panels	CFM	PD (in w.g.)	Dwell Time (sec)	Media (lb)	Ship Weight (Ib)	
DVB242412	23.375 x 23.375	1,500	0.23	0.098	Carbon : 21	30	
	-14	2,000	0.43	0.074	ZK6 : 42	51	
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DVB122412	11.375 x 23.375	750	0.27	0.084	Carbon: 9	15	
7. 2	6	1,000	0.50	0.063	ZK6: 18	24	

All DVB filters are 11.25" deep and available as box-style, single header and double header.** When filter banks incorporate two or more different adsorber sizes, calculate single number approximations of pressure drop and dwell times by multiplying values for each size by their relative filter bank areas and sum the results. <u>Custom sizes available</u>. ** Header Designations: SH = Single Header DH = Double Header

- Constructed of multiple media filled panels, arranged in a V-Bank configuration & sealed in a polished aluminum frame.
- Individual panels 0.625" thick made of corrugated kraft honeycomb bias-cut for low air resistance and longer dwell times.
 - Standard media is 6x8 mesh high activity vapor phase carbon.
 - Panels sealed to the frame with a fire retardant adhesive.
- Filters individually sealed in a plastic bag & placed in individual cartons.

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